

U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICE

INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

ATTY. DOCKET NO.
26860/33:37 USA

ATTY. DOCKET NO.
26860/33:37 USA
APPLICANT
Mark D. Owen
FILING DATE
July 18, 1994

SERIAL NO.
08/276,797

GROUP
2001

2106

RECEIVED

NOV 28 1995

GROUP 2100

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
Am	AG	0 5 8 0 4 0 8	01/26/94	EPC	E23K26	00		
Am	AH	630 2 5 9 1 3	02/03/88	Japan	H01L21	20	English Abstract	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

Am	AI	"Dopant-Induced Excimer Laser Ablation of Poly(tetrafluoroethylene)," APPLIED PHYSICS B:PHOTO-PHYSICS AND LASER CHEMISTRY, Mar 92, Vol b54, No 3, C R Davis et al, pp 227-230
Am	AJ	"Etch-Stop Polymer Machining with an Argon Ion Laser," IBM TECHNICAL DISCLOSURE BULLETIN, Jan 1993, Vol.36., No. 1, Armonk, NY, US, p. 254
	AK	
	AL	
	AM	
	AN	

EXAMINER Gregory Mills DATE CONSIDERED 7-10-96

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.